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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/605,260	09/18/2003	Glenn A. Biery	FIS920030147US1	2259
29505 7	590 03/21/2005		EXAMINER	
DELIO & PETERSON, LLC 121 WHITNEY AVENUE			ANYA, IGWE U	
NEW HAVEN, CT 06510			ART UNIT	PAPER NUMBER
	,		2829	
·			DATE MAILED: 03/21/2005	5

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)	
Office Action Commence	10/605,260	BIERY ET AL.	(m
Office Action Summary	Examiner	Art Unit	
	Igwe U. Anya	2829	
The MAILING DATE of this communication ap Period for Reply	opears on the cover sheet with the c	correspondence addr	ess
A SHORTENED STATUTORY PERIOD FOR REP THE MAILING DATE OF THIS COMMUNICATION - Extensions of time may be available under the provisions of 37 CFR 1 after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above, is less than thirty (30) days, a re - If NO period for reply is specified above, the maximum statutory period - Failure to reply within the set or extended period for reply will, by statu Any reply received by the Office later than three months after the maili earned patent term adjustment. See 37 CFR 1.704(b).	136(a). In no event, however, may a reply be tir ply within the statutory minimum of thirty (30) day d will apply and will expire SIX (6) MONTHS from te, cause the application to become ABANDONE	nely filed /s will be considered timely. the mailing date of this commodities (35 U.S.C. § 133).	munication.
Status			
1) Responsive to communication(s) filed on 07,	January 2005		
· · · · · · · · · · · · · · · · · · ·	is action is non-final.		
3) Since this application is in condition for allow		osecution as to the m	nerits is
closed in accordance with the practice under	· · · · · · · · · · · · · · · · · · ·		•
Disposition of Claims			
4)⊠ Claim(s) <u>1-23</u> is/are pending in the applicatio	, n		
4a) Of the above claim(s) is/are withdra			
5)⊠ Claim(s) <u>1-16 and 19-23</u> is/are allowed.			
6)⊠ Claim(s) <u>17 and 18</u> is/are rejected.			
7) Claim(s) is/are objected to.			
8) Claim(s) are subject to restriction and/	or election requirement.		
Application Papers			
9)☐ The specification is objected to by the Examin	ner.		
10)⊠ The drawing(s) filed on 18 September 2003 is		ted to by the Examir	ner.
Applicant may not request that any objection to the			
Replacement drawing sheet(s) including the corre	ction is required if the drawing(s) is ob	jected to. See 37 CFR	1.121(d).
11)☐ The oath or declaration is objected to by the E	examiner. Note the attached Office	Action or form PTO	-152.
Priority under 35 U.S.C. § 119			
12) ☐ Acknowledgment is made of a claim for foreig a) ☐ All b) ☐ Some * c) ☐ None of:)-(d) or (f).	
1. Certified copies of the priority documer	•	NI-	
2. Certified copies of the priority documer3. Copies of the certified copies of the priority			000
application from the International Burea		ed in this National St	aye
* See the attached detailed Office action for a lis	• • • • • • • • • • • • • • • • • • • •	ed.	
,	1		
Attachment(s)			
Notice of References Cited (PTO-892)	4) Interview Summary	(PTO-413)	
P) Notice of Draftsperson's Patent Drawing Review (PTO-948)	Paper No(s)/Mail Da	ate	50)
 Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08 Paper No(s)/Mail Date 	5)	ratent Application (PTO-1	DZ)
Delegation of Trades and Delegation	· — — — — — — — — — — — — — — — — — — —		

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DETAILED ACTION

Claim Rejections - 35 USC § 102

1. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.
- Claims 17 18 are rejected under 35 U.S.C. 102(e) as being anticipated by Ring (US Patent 6475889).
- 3. Ring teaches a method of fabricating a thin film resistor, comprising: providing a semiconductor wafer (fig. 5 element 20); depositing semi-transparent resistor material (34) on the semiconductor wafer; using the semi-transparent resistor material to eliminate a mask alignment process step (fig. 9, col. 7 lines 46 col. 8 line 42); and

wherein the semi-transparent resistor material is ITO or other metallic material transparent in a portion of the visible spectrum (col. 8 lines 3 - 21, & col. 7 lines 1 - 5).

- 4. Claims 1 16, and 19 23 are allowable, because prior art does not teach inter alia:
- (claims 1, 5) forming a MIM capacitor using a two mask process, that eliminates alignment trenches in the insulating layer; and

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(claims 8, 19, 21, 22) patterning and etching stacked alternating semi-transparent metal layer and dielectric layer, and performing a direct alignment to an underlying metal interconnect layer through the semi-transparent metal layer.

5. Prior art made of record and not relied upon, considered pertinent to applicant's disclosure include Imai (US Patent 6831291).

Remarks

- 6. Applicant's arguments filed January 7, 2005 have been fully considered but they are not persuasive. Ring teaches the transparency of the ITO layer to eliminate alignment masking step (col. 7 lines 62 col. 8 line 15). Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. **THIS ACTION IS MADE FINAL**. Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).
- 7. A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

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Contact Information

8. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Igwe U. Anya whose telephone number is (571) 272-1887. The examiner can normally be reached on M - F 8:30am - 5:00pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, William B. Baumeister can be reached on (571) 272-1722. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Igwe U. Anya Examiner Art Unit 2829

IA

March 14, 2005

DAVID ZARNEKE PRIMARY EXAMINER